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# Silver-decorated reduced graphene oxides as novel building blocks for transparent conductive films†

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We report that silver-decorated reduced graphene oxide (Ag-rGO) hybrid sheets are excellent building blocks for transparent conductive films (TCFs). Unlike rGO films that exhibit large sheet resistances, Ag-rGO films are much more conductive. By tuning the silver content, Ag-rGO film can achieve a sheet resistance as low as  $56 \Omega \text{ sq}^{-1}$  at  $\sim 80\%$  transparency, which is at least two orders of magnitude lower than that of rGO films. A significant increase in conductivity can be qualitatively explained by heavy electron doping of individual rGO sheets and "percolation" doping of the entire rGO film by silver nanoparticles (AgNPs). Analysis of the electro-optical performance indicates that the hybrid film is even far superior to single-walled carbon nanotube networks. In addition to their highly conductive nature, Ag-rGO hybrid films are flexible and environmentally stable, making them attractive for flexible device applications under severe conditions. Further optimization in the synthesis and fabrication schemes may lead to better TCFs with performances comparable to indium-doped tin oxide.

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## 1. Introduction

Graphene, a single layer of graphite, exhibits remarkable properties that have attracted a vast amount of scientific and technological interest. At room temperature, the electrons in graphene can travel thousands of interatomic distances without being scattered, resulting in very high carrier mobility.<sup>1</sup> The sheet resistance ( $R_s$ ) of graphene varies with the number of layers ( $n$ ) as  $R_s \approx 62.4/n \Omega \text{ sq}^{-1}$  for highly doped graphene, and the transmittance ( $T$ ) varies with  $n$  as  $T \approx 100 - 2.3n$  (%),<sup>2,3</sup> indicating that a monolayer graphene is almost totally transparent. In addition to the remarkable electronic and optical properties, graphene is highly flexible and chemically resistant. Therefore, it is considered as an ideal transparent conductive film (TCF), which is widely used in applications such as photovoltaic devices, flat panel displays, organic light emitting diodes, touch screens, and transparent heaters *etc.*<sup>4,5</sup> Although dominant TCFs used nowadays, such as indium-doped tin oxide (ITO), have exceptional optoelectronic properties, they suffer from considerable drawbacks, including increased material costs, costs associated with vacuum deposition, and brittleness, all of which are motivating the search for other cost-effective alternatives.<sup>6,7</sup>

Undoped graphene has a low charge carrier density, and thus a high sheet resistance, as a result of its vanishing density of states at the Dirac point. To increase the number of charge

carriers, various doping methods have been suggested,<sup>8</sup> which typically involves the transfer of electrons from graphene (or the dopant) to the dopant (or the graphene). This can be achieved by simply depositing metals on graphene. For example, Au deposition on graphene induces p-doping, whereas Ag deposition induces n-doping.<sup>9</sup> Another factor limiting the conductivity of graphene is its polycrystalline nature, especially for graphene grown by chemical vapor deposition (CVD). Grain boundaries separate an entire graphene film into small sizes ranging from a few micrometers to a few tens of micrometers.<sup>10</sup> At these boundaries transport charge carriers are severely scattered. To encounter this problem, a so-called "percolation" doping is usually adopted to open up new conducting channels by bridging the grain boundaries with conducting metal nanowires.<sup>10</sup> For example, silver nanowire (AgNW)-doped graphene film can yield a stabilized sheet resistance of  $13 \Omega \text{ sq}^{-1}$  at 88% transparency,<sup>10</sup> which is superior to typical reported values for ITO.

Although charge carrier doping and "percolation" doping have been proved to be very effective, they are usually performed on CVD-grown graphene, in which the operation costs are very high. For reduced graphene oxide (rGO) films,<sup>11,12</sup> studies about the effects of doping treatment are relatively limited. This, however, should be of great significance, since the processing of rGO film is solution-based and therefore it can be produced in high yields at relatively low costs.<sup>12</sup> Like CVD-grown graphene, rGO film has certain disadvantages. The crystal defects on individual rGO sheets degrade the conductivity of each sheet, and numerous resistive rGO-rGO junctions limit the conductivity of entire film. This results in a relatively large sheet resistance ( $R_s \geq 1 \text{ k}\Omega \text{ sq}^{-1}$  at  $T \geq 85\%$ ).<sup>13,14</sup> In a similar manner, rGO film can be treated with charge carrier doping and

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“percolation” doping to improve its conductivity. For example, Kholmanov *et al.* found that Au nanoparticles (AuNPs) can effectively dope individual rGO sheets, resulting in a decrease in film resistance from 49.2 k $\Omega$  sq<sup>-1</sup> to 28.6 k $\Omega$  sq<sup>-1</sup>.<sup>15</sup> Subsequent “percolation” doping with AgNWs created conducting channels between the rGO sheets, and drastically decreased the sheet resistance to 26  $\Omega$  sq<sup>-1</sup> (at 83% transparency). In their approach, however, three kinds of stable nanoparticle dispersions, *i.e.* rGO, AuNP, and AgNW dispersions were prepared prior to the film fabrication, which complicated the whole process and made it time-consuming. In this study, we report a general and more elegant doping strategy for rGO films by using Ag-decorated rGO as the building blocks for the TCFs. The sheet resistance of the resultant film could reach 56  $\Omega$  sq<sup>-1</sup> with  $T \geq 75\%$  in the 500–1100 nm wavelength range. Such a low sheet resistance arises from heavy electron doping of individual rGO sheets and a simultaneous “percolation” doping of the entire film by silver. Our finding suggests that through further process development, Ag-rGO hybrid films could become very attractive for various optoelectronic applications.

## 2. Experimental

### Materials

Graphite flakes, silver nitrate (AgNO<sub>3</sub>) and *N,N*-dimethylformamide (DMF) were purchased from Sigma-Aldrich, Inc. Hydrazine monohydrate (N<sub>2</sub>H<sub>4</sub>·H<sub>2</sub>O; 80 wt%) was supplied by Tianjin Fuyu Chemical Inc., China. All chemicals were used as received without further purification.

### Preparation of Ag-GO dispersions

Graphite oxide was prepared from graphite flakes by a Hummers process.<sup>11</sup> It was readily exfoliated into monolayer GO sheets in water (Fig. S1, ESI†). Ag-GO hybrid sheets were then synthesized by adding AgNO<sub>3</sub> and DMF to aqueous GO, and heating at 90 °C (Fig. S2, ESI†). The Ag-GO hybrid sheets were synthesized by a facile solution-based route. Typically, two GO solutions (20 ml, 2 mg ml<sup>-1</sup>) were firstly prepared by stirring graphite oxide solids in deionized water for 4 h, followed by sonicating in a bath sonicator (Tru-Sweep 575 HTAG, Crest Ultrasonics) for 1 h. To each of these solutions 1 ml AgNO<sub>3</sub> solution (4 and 20 mg ml<sup>-1</sup>, respectively) was then pipetted. The mixed solutions were then briefly hand-mixed, followed by addition of 6 ml DMF to each and a further mild sonication for 1 h. Finally they were heated at 90 °C in an oven for 4 and 12 h. The obtained Ag-GO hybrid sheets were denoted as hybrid I and hybrid II, respectively. Their dispersions were homogeneous and stable with no precipitates.

### Fabrication of Ag-rGO films

Ag-rGO films were prepared by vacuum filtration followed by a wet transfer. Typically, small volumes (20–100  $\mu$ l) of as-prepared Ag-GO dispersions were diluted down with 25–700 ml deionized water and were subjected to half an hour low power sonication. Ag-GO films were then prepared by vacuum filtration of these dilute dispersions using commercial mixed cellulose ester (MCE)

filter membranes (MF-Millipore membrane, mixed cellulose esters, hydrophilic, 0.2  $\mu$ m, 47 mm). To recover the electrical conductivity of GO, 500 ml of 5 wt% N<sub>2</sub>H<sub>4</sub>·H<sub>2</sub>O solution was then filtered. A dilute N<sub>2</sub>H<sub>4</sub>·H<sub>2</sub>O solution was utilized because it could effectively reduce GO sheets without causing film fragmentation and/or delamination.

The as-prepared Ag-rGO hybrid films were then transferred to poly(ethylene terephthalate) (PET) or glass substrates using heat and pressure while the films were still wetted with water. Briefly, the substrate was placed on a hotplate and heated at 90 °C. Ag-rGO film/MCE membrane was placed on the substrate in which wet Ag-rGO film came in contact with the substrate. It is of crucial importance here that no bubbles should be incorporated between the Ag-rGO film and the substrate to achieve a successful transfer. A 2.5 kg weight was then placed on top for 6 h, causing Ag-rGO hybrids and the substrate into an intimate contact. This gave sufficient adhesion of Ag-rGO film to the substrate such that the MCE membrane was delaminated readily for repetitive use, leaving the Ag-rGO film on the substrate. These films were then washed in an acetone liquid bath at room temperature for 30 min, and then dried at 120 °C overnight.

### Characterizations

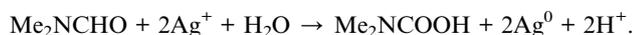
Ag-GO hybrid sheets and assembled Ag-rGO films were examined in a transmission electron microscope (TEM; Philips FEG CM 20). TEM samples of assembled Ag-rGO films were prepared by carefully immersing Ag-rGO/MCE membrane in an acetone bath, followed by collecting the floating films on copper grids. The surface morphology of Ag-rGO films was observed in a field emission scanning electron microscope (SEM; Jeol FEG JSM 6335). The roughness of the films was examined by an atomic force microscope (AFM; Veeco Nanoscope V). The chemical states of carbon in the films were determined from X-ray photoelectron spectroscopy (XPS; PHI-5802; Physical Electronics, Chanhassen, MN) under Al K $\alpha$  excitation. The structure and internal contacts within the films were detected by X-ray diffraction (XRD) using a Philips 220 X'pert diffractometer with Cu K $\alpha$  radiation ( $\lambda = 1.54178$  Å). The sheet resistance was measured using a standard in-line four probe method with a multimeter (Model RTS-3, 4 Probes Tech Inc., China). Four Ag contacts (each with dimensions of 300  $\times$  300  $\mu$ m<sup>2</sup> to ensure good electrical contact and minimize the potential influence of local inhomogeneity in the films) were deposited (from silver paste) onto the films by a mask. Optical transmittance measurements were carried out using a Perkin Elmer Lambda 2S UV-vis spectrophotometer. All electrical/optical measurements of the films were performed at ambient conditions. The work function of Ag-rGO films was measured by ultraviolet photoelectron spectroscopy (UPS; AXIS Ultra DLD, KRATOS Inc.) with a He 1 $\alpha$  ( $h\nu = 21.2$  eV) UV source in ultrahigh vacuum ( $5 \times 10^{-8}$  Torr).

## 3. Results and discussion

GO contains hydroxyl and epoxide functional groups on their basal planes, as well as carbonyl and carboxyl groups at its sheet



edges, which impart negative charges to these sheets in water. Positively charged Ag ions would therefore attach to GO through electrostatic attraction. As is well known, DMF is a weak reducing agent and can effectively reduce Ag ions by the following reaction:<sup>16</sup>



Once reduced, the resultant Ag atoms would act as nucleus and trigger the growth of AgNPs on GO. TEM micrographs of the obtained Ag-GO hybrids show that AgNPs are uniformly distributed on the GO surfaces (Fig. 1A and B). The size of

AgNPs can be tuned by the amount of silver sources, and reaches  $\sim 25$  nm for hybrid I, and  $\sim 60$  nm for hybrid II. High-magnification TEM micrographs, however, reveal that a huge number of smaller AgNPs are densely distributed on the sheets (Fig. 1C). The lateral distance between adjacent AgNPs is smaller than 50 nm, most frequently below 20 nm. This is comparable to the sizes of intact graphene islands on GO,<sup>17</sup> suggesting that most functionalized sites are decorated with AgNPs. Electron diffraction patterns of larger AgNPs demonstrate a polycrystalline nature, implying their growth from the aggregation of small nanoparticles.

We used the vacuum filtration method to fabricate Ag-GO films with controllable thicknesses. The vacuum filtration process is self-regulating, allowing good control over the film thickness and nanoscale uniformity by simply varying the Ag-GO concentration and/or the filtration volume. With the availability of a large-scale filter, this process can be used to prepare large-area films (diameter of  $\sim 9$  cm).<sup>18</sup> After filtration these films were *in situ* reduced by filtering dilute (5 wt%)  $\text{N}_2\text{H}_4 \cdot \text{H}_2\text{O}$  solution through the films. After reduction the films darkened, suggesting the restoration of the  $\pi$ -electron system in GO. Comparing to  $\text{N}_2\text{H}_4$  vapor reduction with effective reduction for uppermost layers of GO film,<sup>19</sup> our approach can achieve a thorough film reduction. This is because the  $\text{N}_2\text{H}_4 \cdot \text{H}_2\text{O}$  solution can permeate through the hybrid film and react with every GO layer; hence completely converting Ag-GO film to Ag-rGO film. XPS spectra of the reduced films reveal a significant removal of oxygen moieties when compared to the GO film (Fig. S3<sup>†</sup>). Additionally, an uptake of nitrogen occurs after reduction, which is caused by residual hydrazine at the film surfaces.<sup>19,20</sup>

TEM micrographs of the resultant Ag-rGO films show that they are dense and compact with spatial uniformities over

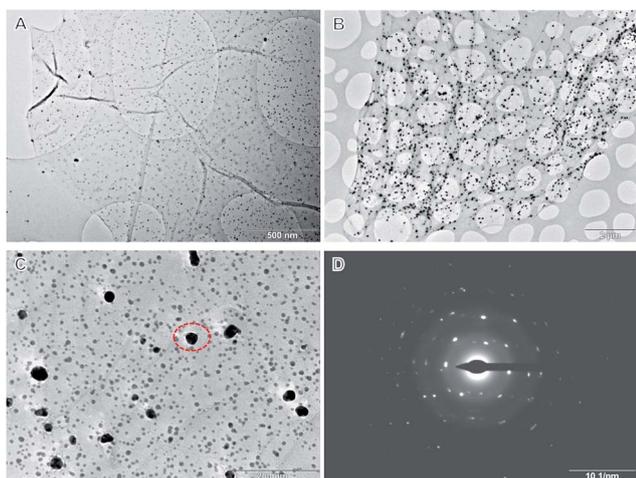


Fig. 1 TEM micrographs of Ag-GO hybrids. (A): Hybrid I; (B): hybrid II. (C) High-magnification TEM micrograph of Ag-rGO hybrid II. (D) Electron diffraction pattern of anchored AgNP as denoted in (C).

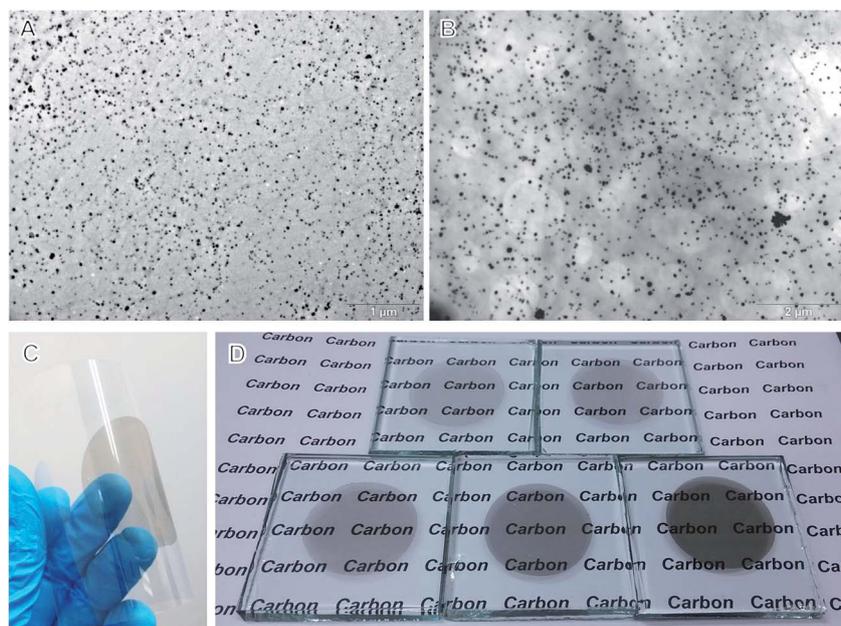


Fig. 2 (A and B) TEM micrographs of continuous Ag-rGO film I and Ag-rGO film II. (C and D) Photographs of transferred Ag-rGO hybrid film II on PET and glass substrates. The films have a diameter of  $\sim 4$  cm.



a relatively large area (Fig. 2A and B). Due to their robustness, these films can be readily transferred onto a PET or glass substrate using heat and pressure (Fig. 2C and D). The yield of the transfer process is nearly 100% and independent of substrate, indicating strong interactions between the films and the substrate to obtain well-adhered films.

By controlling the volume of filtered suspension, electro-optical properties of the films can be readily tuned. Fig. 3A shows that the optical transmittance of both film I and film II is almost linearly dependent on the filtration volume. For filtration volume  $\leq 700$  ml, the transmittance is above  $\sim 50\%$  for film I with sheet resistance ranging between  $40 \Omega \text{ sq}^{-1}$  and  $32 \text{ M}\Omega \text{ sq}^{-1}$  (Fig. 3B). For film II, the transmittance is above  $\sim 40\%$  with sheet resistance ranging between  $11 \Omega \text{ sq}^{-1}$  and  $16 \text{ k}\Omega \text{ sq}^{-1}$  (Fig. 3B). At  $T = 75\%$ , the sheet resistance is  $\sim 30 \Omega \text{ sq}^{-1}$  for film II, which is much lower than that of rGO films (Fig. 3C). The dramatic reduction in sheet resistance indicates the effectiveness of Ag-rGO hybrid sheets as the building blocks for high-performance TCFs. XRD patterns of these hybrid films reveal that the peak at  $\sim 26^\circ$  (stacked graphene sheets) is missing (Fig. 3D), suggesting that most stacked rGO sheets (which are present in rGO film) are delaminated to accommodate the anchored AgNPs. Due to the huge amount of AgNPs (Fig. 1), numerous AgNP-rGO contacts are created accordingly. This would significantly alter the electrical transport properties of the rGO film, as will be discussed next.

The microstructure of these hybrid films was examined by SEM (Fig. 4). It showed that a huge number of AgNPs were evenly

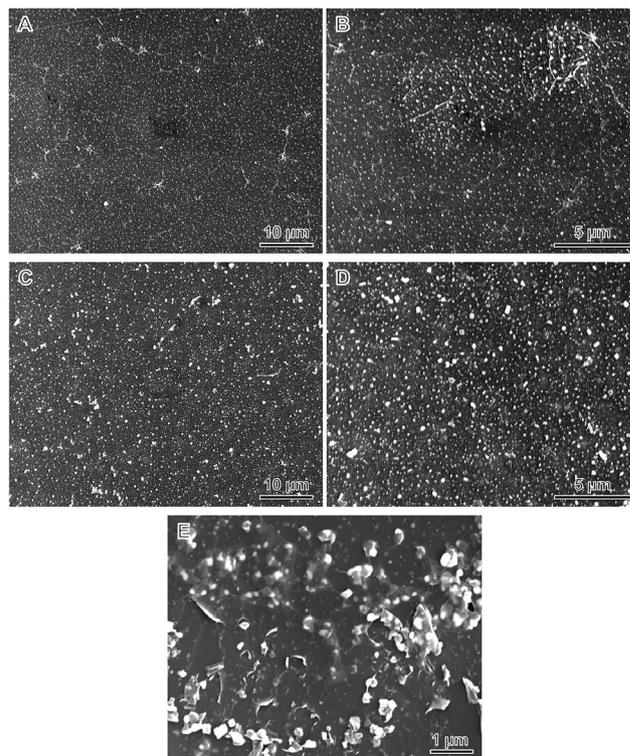


Fig. 4 (A and B) are low- and high-magnification SEM micrographs of Ag-rGO hybrid film I ( $\sim 88\%$  transparency) on PET. (C, D and E) are low- and high-magnification SEM micrographs of Ag-rGO hybrid film II ( $\sim 80\%$  transparency) on PET.

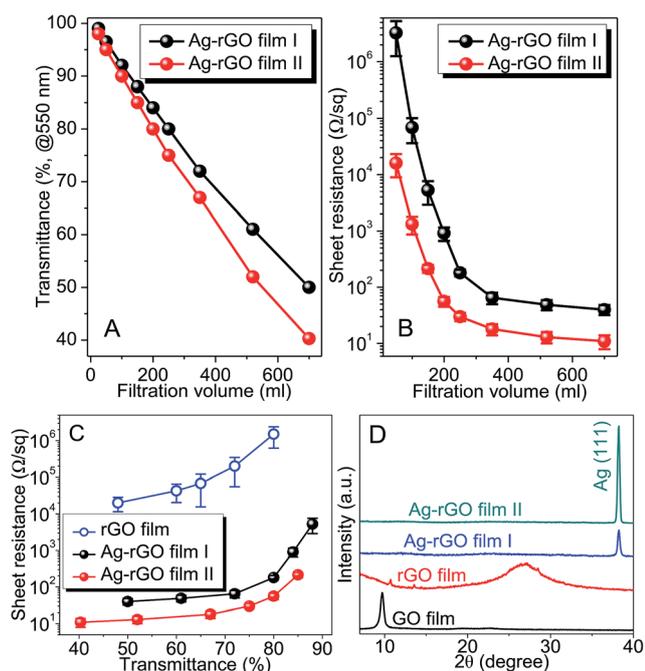


Fig. 3 (A) Optical transmittance and (B) sheet resistance of Ag-rGO films as a function of filtration volume. (C) Comparison between sheet resistance–transmittance of rGO film and Ag-rGO films. Error bars show one standard deviation for 5 measurements. (D) XRD patterns of Ag-rGO film I and II on PET. XRD patterns of GO and rGO film are given for the purposes of comparison.

distributed in the hybrid films. The compactness of the films was maintained, indicating the transfer process would not negatively influence the film structure. Graphene possesses an intrinsic tensile strength of 130 GPa and in plane Young's modulus of 1 TPa,<sup>21</sup> and excellent bending behavior due to its exceptionally low flexural rigidity.<sup>22</sup> Therefore, the intimate contact between the Ag-rGO hybrid sheets in our films is considered of mechanical control in origin. This mechanical force reduces the air gap between these hybrid sheets and compresses them into an integrated continuous film, thereby improving AgNP-rGO contacts. Due to the larger sizes of incorporated AgNPs, thus Ag-rGO hybrid film II exhibits a relatively larger roughness (Fig. S4 and Table S1†). However, this should not pose a problem and can be effectively addressed by applying a thin polymer layer such as poly(3,4-ethylenedioxythiophene)/poly(styrenesulfonic acid) layer to smooth the surface for satisfying the needs of real applications.<sup>23</sup>

The intimate contacts between AgNPs and rGOs would alter the electronic properties of both samples. Fig. 5A shows the Ag  $3d_{5/2}$  and Ag  $3d_{3/2}$  XPS spectra for both bulk Ag and Ag-rGO films. Two bands at 368 and 374 eV, ascribed to Ag  $3d_{5/2}$  and Ag  $3d_{3/2}$  binding energies, are identified for bulk Ag. These two bands shift remarkably to lower energies at 367.3 and 373.3 eV for Ag-rGO films. This 0.7 eV shift is caused by the electron transfer from AgNPs to rGO. It is known that the binding energy of the higher ionic state of Ag is lower than that of zero-valent Ag, due to shifts in the initial-state potential of ionic charge



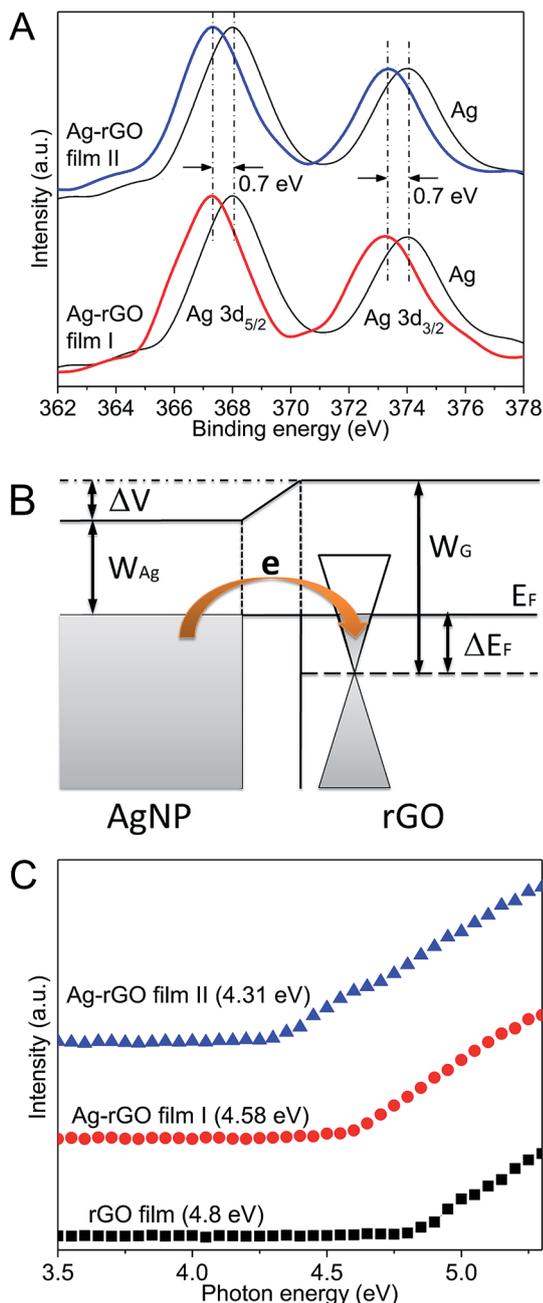


Fig. 5 (A) Ag 3d<sub>5/2</sub> and Ag 3d<sub>3/2</sub> XPS spectra of bulk Ag and Ag-rGO film I and Ag-rGO film II. (B) Energy band diagram of AgNP-rGO contact. (C) UPS spectra near the secondary-electron threshold region of rGO film, Ag-rGO film I and Ag-rGO film II.

and the lattice potential. Since the work function of Ag (4.2 eV) is smaller than that of graphene (4.8 eV),<sup>24</sup> electron transfer from AgNPs to rGO automatically occurs within the Ag-rGO hybrid films. This would effectively dope rGO with more electrons and raise its Fermi level above the conical point (Fig. 5B).

The phenomenon of electron transfer is further analyzed by UPS, as shown in Fig. 5C. The work function of rGO film, Ag-rGO film I and II can be determined from the spectra of second electron threshold. It can be found that the work function decreases from 4.8 eV for rGO film to 4.58 eV for Ag-rGO film I, and to 4.31 eV for Ag-rGO film II.

and to 4.31 eV for Ag-rGO film II. The decrease in work function due to AgNPs incorporation into rGO indicates a change in the surface potential. It implies an upward shift of the Fermi level, which is consistent with the XPS results. As a result, a decrease in sheet resistance of Ag-rGO films can be attributed to the increased electron concentration due to n-doping by AgNPs. Considering the huge number of AgNPs within the hybrid films, this n-doping effect plays an important role in enhancing the film conductivity.

In addition to the n-doping effect, AgNPs would connect rGO sheets and “percolation” dope the rGO film. The concept of “percolation” doping was initially described for CVD-graphene when segregated domains were connected across grain boundaries by individual silver nanowires.<sup>10</sup> Although rGO film is different from CVD-graphene, the highly resistive rGO-rGO junctions ( $R_j \approx 150 \text{ M}\Omega$ )<sup>25</sup> in rGO film are comparable to the grain boundaries in CVD-graphene. Electrically bridging adjacent or overlapped rGO sheets with AgNPs would, therefore, create additional conducting channels between these sheets and improve the transport properties of entire film. Due to the n-doping effect, silver-graphene junction is much more conductive. For weakly coupled silver-graphene junction,  $R_j \approx 550 \Omega$ ; while for intimate silver-graphene contact,  $R_j \approx 0 \Omega$ .<sup>10</sup> This same mechanism of “percolation” doping has been applied to improve the conductivity of rGO film by coupling it with sparse AgNW or copper nanowire (CuNW) network.<sup>15,26</sup>

The effects of electron doping and “percolation” doping on film conductivity can be well described by the resistor network model as illustrated in Fig. 6. The n-doping effect improve the conductivity of individual rGO sheets, whereas the “percolation” doping creates new conducting channels between adjacent or overlapped rGO sheets. A combination of these two effects leads to a drastic decrease in film resistance.

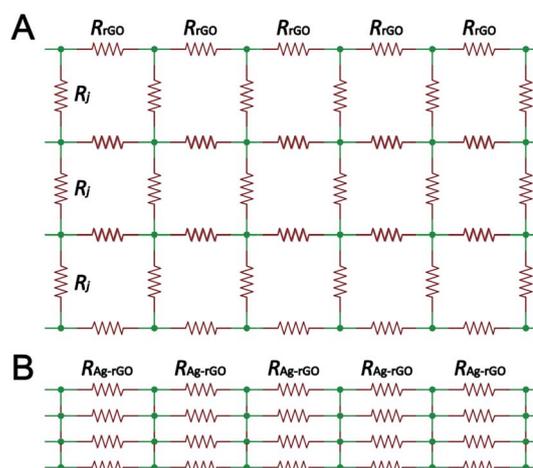


Fig. 6 Illustration of the resistor network model describing a four-layer stacked (A) rGO film and (B) Ag-rGO film. For rGO film, large resistance of individual rGO sheets and rGO-rGO junctions ( $R_j$ ) result in a large sheet resistance. For Ag-rGO films, the resistance of rGO sheets decreases due to the n-doping effect, and AgNPs bridge the resistive rGO-rGO junctions.  $R_{rGO}$  and  $R_{Ag-rGO}$  ( $< R_{rGO}$ ) denote the intrinsic resistance of individual rGO sheets and Ag-rGO hybrid sheets, respectively.



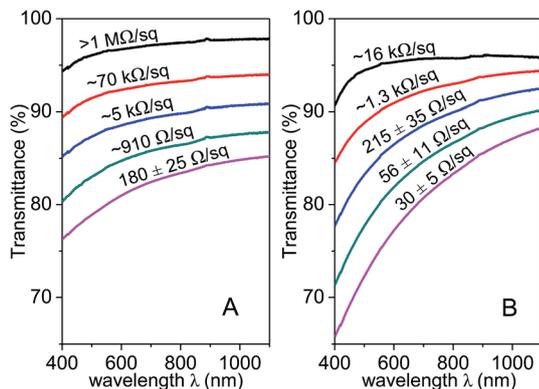


Fig. 7 Optical transmittance of (A) Ag-rGO film I and (B) Ag-rGO film II at different sheet resistances.

In contrast to the flat transmittance–wavelength spectra of graphene films,<sup>27</sup> the transmittance of Ag-rGO films shows a pronounced dependence on the light wavelength (Fig. 7), due to light absorption caused by surface plasma resonance (SPR) of AgNPs. This involves specific scattering interactions between the impinging light and the AgNPs. In particular, oscillating electric field of incoming light causes coherent oscillation of electrons in the conduction band of the nanoparticles, resulting in a concomitant oscillation of electron cloud surrounding the Ag nuclei. SPR generally causes light absorption at  $\sim 410$  nm.<sup>28,29</sup> Nevertheless, the absorptions are highly dependent on the nanoparticle size, and the large AgNPs scatter predominantly in the forward direction (which is crucial for reducing surface reflectance), owing to the increase of radioactive efficiency and excitation of high-order modes.<sup>30</sup> Therefore, Ag-rGO film II is more suitable for solar cell applications. AgNPs incorporated into the film can serve as an anti-reflection coating. They scatter more light into the cell and scatter at oblique angles to improve light-trapping, hence enhancing the device efficiency.<sup>30</sup>

The relationship between transmittance and sheet resistance for Ag-rGO films and other nanostructured TCFs is plotted in Fig. 8A. At sheet resistances below  $\sim 1.3$  k $\Omega$  sq<sup>-1</sup>, films made from these Ag-rGO hybrid sheets are superior to similar films of rGOs and SWNTs made by spin coating and Mayer rod coating,<sup>14,31</sup> respectively. At  $\sim 75\%$  transparency, the sheet resistance of Ag-rGO film II ( $30 \Omega$  sq<sup>-1</sup>) is about 30 times lower than that of rGO film ( $\sim 1$  k $\Omega$  sq<sup>-1</sup>). From the literature, continuous CVD-grown graphene films have superior performance to Ag-rGO films.<sup>8</sup> However, they must be grown at a high temperature (1000 °C), and an additional step must be adopted to transfer graphene from metal substrates to non-conductive substrates. On the other hand, the lower processing temperatures and fabrication costs give Ag-rGO film a pronounced advantage over CVD-graphene in terms of cost consideration.

Thin films of AgNWs and CuNWs also outperform Ag-rGO films in terms of electro-optical performance.<sup>32,33</sup> However, the long-term electrical stability of these films is a major concern. Atmospheric sulfur tends to convert Ag into Ag<sub>2</sub>S, which is less conductive and has a stronger optical absorption.<sup>34</sup> Copper is even more reactive, and it reacts with oxygen at ambient

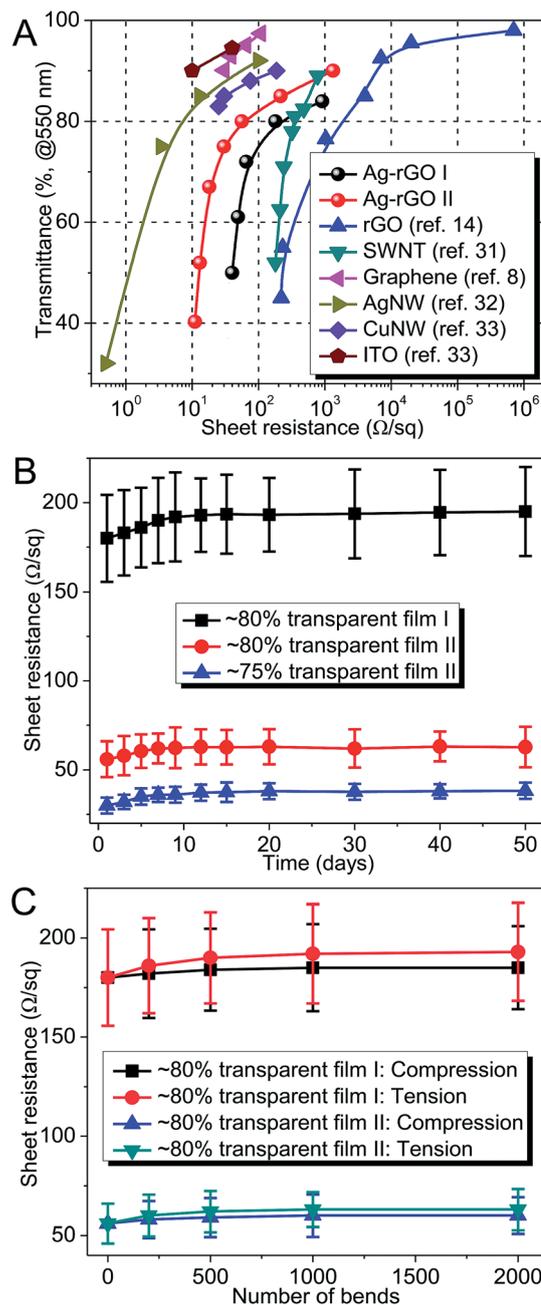


Fig. 8 (A) Plot of transmittance (at 550 nm) versus sheet resistance for films of Ag-rGO, rGO, CVD-graphene, SWNTs, AgNWs, CuNWs and ITO. (B) Plot of sheet resistance versus time for Ag-rGO hybrid films (80, 80 and 75% transparent from top to bottom) exposed to air for 50 days. (C) Plot of sheet resistance versus number of bends for Ag-rGO film I (80% transparency) and II (80% transparency) on PET. Error bars show one standard deviation for 5 measurements.

conditions and loses its conductivity more quickly.<sup>34</sup> In order to examine the oxidation rate of Ag-rGO films, we exposed hybrid films with different conductivities in air and measured their sheet resistances periodically. Fig. 8B showed that over a period of 50 days, the sheet resistances remained fairly constant. There was a slight increase in the first week, but from the second week onward the sheet resistance remained within one standard



deviation. This initial increase and subsequent stability is due to the oxidation of surficial AgNPs that are not covered by rGO. Although this is not a comprehensive test under a variety of environmental conditions, Fig. 8B illustrates that, even without any barrier materials to protect the films, they are fairly resistant to air oxidation.

Another advantage of Ag-rGO films is their excellent flexibility. To demonstrate this, Ag-rGO films on PET are subjected to both compressive and tensile bending cycles to a radius of curvature of  $\sim 3$  mm. Fig. 8C shows that these films exhibit little change in sheet resistance after 2000 bends. Such superior stability against bending deformation makes them very attractive for flexible electronic applications. By contrast, ITO on PET tends to lose its conductivity after just 50 bends,<sup>33</sup> due to the formation of micro-cracks.<sup>35</sup>

Through enhanced chemical manipulation of solution-processable GO, the size and density of AgNPs can be more accurately controlled. This strategy plays an important role in achieving higher film conductivities per unit thickness, possibly allowing the use of thinner films to attain high transparency. Besides, the approach of vacuum filtration and transfer is a very slow process. Proper optimization of the rheological/wetting behavior of Ag-GO dispersions can be achieved through direct and scalable approaches such as rod coating. Further study of this will be presented elsewhere. The importance of realizing all these studies lies in the abundance, facile synthesis and relatively inexpensive nature of Ag-rGO when compared to SWNTs, CVD-graphene, AgNWs, CuNWs and ITO. Developing a precise control over growth of AgNPs on GO and more efficient film fabrication approaches will be the objectives of future research.

## 4. Conclusions

We have shown the potential of Ag-rGO as novel building blocks for fabricating transparent conductors. Compared to rGO films, Ag-rGO hybrid films showed a much lower sheet resistance at a given transparency. This was attributed to the n-doping and “percolation” doping effects of AgNPs, which increased the number of electrons within individual rGO sheets and reduced the rGO-rGO junction resistance. The electro-optical performance of Ag-rGO films was analyzed and compared with other TCFs, indicating that our films outperformed most carbonaceous films reported in the literature, especially rGO films. Although the synthesis scheme presented in this study was based on Ag-rGO, it can be extended to rGO decorated by other inexpensive metal nanoparticles, such as copper. The results presented in this study, in terms of utilizing water processable metal nanoparticle-decorated GO sheets as building blocks for fabricating films, open the opportunities for fabricating low-cost TCFs.

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